



03-02-06

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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.: 10/706,862 Confirmation No.: 6724  
Applicant(s): Ogihara, et al.  
Filed: November 12, 2003  
Art Unit: 1711  
Examiner: Irina S. Zemel  
Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND  
METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM,  
AND SEMICONDUCTOR DEVICE

Docket No.: 035576/271443  
Customer No.: 00826

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT UNDER 37 C.F.R. § 1.121**

Sir:

In response to the Office Action dated December 1, 2005, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims beginning on page 2 of this paper.

**Remarks/Arguments** begin on page 3 of this paper.